

Substitute for form 1449B/PTO

**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**

(use as many sheets as necessary)

Complete if Known

Application Number	09/388,265
Filing Date	September 1, 1999
First Named Inventor	
Art Unit	2811
Examiner Name	H. Vu
Attorney Docket Number	082666-000100US

Sheet 1 of 1

U.S. PATENT DOCUMENTS+					
Examiner Initials*	Cite No. ¹	Document Number Number Kind Code ² (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
✓	AA	US-5,614,727	03-25-1997	Mauri et al.	—
✓	AB	US-Re: 35,665	11-18-1997	Lin et al.	—
✓	AC	US-5,760,423	06-02-1998	Kamakura et al.	—

FOREIGN PATENT DOCUMENTS								
Examiner Initials*	Cite No. ¹	Foreign Patent Document			Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T ²
		Country Code ³	Number ⁴	Kind Code ⁵ (if known)				
✓	AD	JP	10-233382	A	09-02-1998	—	—	<input checked="" type="checkbox"/>
✓	AE	JP	10-233529	A	09-02-1998	—	—	<input checked="" type="checkbox"/>
✓	AF	JP	10-270758	A	10-09-1998	—	—	<input checked="" type="checkbox"/>

NON PATENT LITERATURE DOCUMENTS			
Examiner Initials *	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²
✓	AG	BIRKS, N. et al.; "Introduction to High Temperature Oxidation of Metals"; 1983, Edward Arnold, pp. 66-90.	
✓	AH	JARZEBSKI, Z.M.; "Oxide semiconductors", 1973, Pergamon Press, pp. 150-189.	

Examiner Signature	HUNG VU	Date Considered	01/03/06
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹ Applicant's unique citation designation number (optional). ² Applicant is to place a check mark here if English language Translation is attached.